



JPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Shunichi SEKI et al.

Group Art Unit: 2826

Application No.: 10/686,634

Examiner: S. Wilson

Filed: October 17, 2003

Docket No.: 104741.01

For: METHOD OF FORMING THIN FILM PATTERNING SUBSTRATE INCLUDING
FORMATION OF BANKS (AS AMENDED)

AMENDMENT UNDER 37 CFR §1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the February 10, 2005 Office Action, please amend the above-identified application, as follows:

Amendments to the Claims as reflected in the listing of claims;

Remarks.